

## LAM IS NEW EDITOR OF *APL*; NEW ASSOCIATE EDITORS JOIN *JCP*

After nearly five years as editor of *Applied Physics Letters*, Hartmut Wiedersich, of the materials science division at Argonne National Laboratory, is retiring to North Carolina. Nghi Q. Lam, also in the materials science division at Argonne, will be *APL*'s new editor. In other publishing news, Marshall Fixman and Branka Maria Ladanyi, both at the department of chemistry at Colorado State University, in Fort Collins, are new associate editors at the *Journal of Chemical Physics*.

Wiedersich, who received his PhD in physics and metallurgy from the University of Göttingen in 1954, did research in crystal growth, the Mössbauer effect, crystal defects and effects of irradiation on solids. Wiedersich's colleague Steve Rothman, the editor of the *Journal of Applied Physics*, told PHYSICS TODAY that Wiedersich "enhanced the status of *APL* as the world's most prestigious applied physics journal during a very rough period for physics research." Rothman noted that Wiedersich managed a 25% increase in the number of submitted manuscripts and guided *APL* in its first steps toward electronic publication (see PHYSICS TODAY, June, page 66).

Wiedersich predicted that the transition will be smooth, because he and Lam have been working together the past few months. Lam will be in charge on the first of November.

Lam, who was born in Vietnam in 1945, received his BS in physical metallurgy from the Université Laval, in Quebec, Canada, in 1968 and his PhD in materials science from McMaster University, in Ontario, Canada, in 1971. Lam has spent most of his professional career at Argonne, where he is now a senior scientist in the irradiation and kinetic effects group. His research interests include atomic defects, diffusion, segregation, phase transformations, sputtering, ion-beam analysis and computer simulations.

Lam has also had several positions at other laboratories in Europe and

in the US. He worked in France as a guest scientist at the Centre d'Etudes Nucléaires, in Saclay, from 1979 to 1980 and at the Centre Européen de Calcul Atomique et Moléculaire, in Orsay, in 1983. He was an adjunct professor in the division of medical physics in the Chicago Medical School during 1976-81 and 1986-87.

Lam's appointment was recommended by a search committee headed by Alan Fowler, of IBM Thomas J. Watson Research Center, in Yorktown Heights, New York.

### At *JCP*

For the last 11 years John Light and Donald Levy, both of the James Franck Institute at the University of Chicago, have shared tasks as editor and associate editor, respectively, of the *Journal of Chemical Physics*; now, with the addition of Fixman and Ladanyi, they will have some assistance. Although no increase in the number of published pages is expected at present, *JCP* will be doubling its production frequency next year, appearing four times a month instead of two.

Fixman received his AB in chemistry from Washington University, in Saint Louis, in 1950 and his PhD in physical chemistry from MIT in 1954. His research interests include theoretical chemistry, statistical mechanics and polymer theory and simulations. Ladanyi obtained a BSc in physics from McGill University, in Montreal, Canada, in 1969. Her PhD, which she received from Yale University in 1973, is in chemistry, and her research interests include theoretical physical chemistry, statistical mechanics and the theory of solvent effects on chemical reaction rates and equilibria.

Original manuscripts submitted to *JCP* will still go to the University of Chicago, which remains the center of the operation. But a satellite office, linked electronically to Chicago, has been established in Fort Collins.

From there Fixman and Ladanyi will be able, for example, to search through electronic files on *JCP* computers in Chicago.

Also, since about 40% of the incoming papers deal with what might be termed "condensed matter chemical physics," the full peer review process for these papers will be managed from Colorado. After receipt is registered in Chicago, the papers will be sent via overnight mail to Fort Collins.

## APS ISSUES STATEMENT ON EQUAL OPPORTUNITY

The American Physical Society has issued a statement outlining its support of equal opportunity in professional activities. The statement was drafted by the APS committees on membership, minorities and the status of women in physics.

In general the APS statement "re-affirm[s] the society's long-standing commitment to removing barriers impeding the entry of women and minorities to the career of physics, and to fostering their full-fledged participation in our profession." It further states that APS and its members are required to "conduct their professional activities without discrimination or harassment in regard to personal factors," including gender, race, national origin, age, religion, marital status, political views, sexual orientation and disability.

In 1993 the American Astronomical Society changed its bylaws to include similar language (see PHYSICS TODAY, November 1993, page 85). But unlike the AAS amendment, the APS statement contains guidelines for implementation. The APS statement places responsibility for dealing with issues of discrimination on APS elected officers and governance committees. In addition, the statement urges that "any person who becomes aware of inappropriate conduct should contact the executive officer of the society." ■